IN THE CLAIMS:

Cancel claims 6 and 14 - 17.

Amend claims 1 and 7 as set forth below:

- 1. (currently amended) A system for precisely controlling an amount of flatness or curvature of a lapping plate, the system comprising:
 - a rotatable platform;
- a lapping plate mounted to the rotatable platform for rotation therewith;

 a holder having a workpiece located between the holder and the lapping plate;

 an abrasive slurry located between the lapping plate and the workpiece; [[and]]

 means for controlling a temperature of the lapping plate and thereby precisely

 manipulating an amount of flatness or curvature of the lapping plate[[.]]; and wherein

 the temperature of the lapping plate is adjusted during a charge process to selectively charge

 different areas of the lapping plate in a dictated order.
- 2. (unchanged) The system of claim 1, wherein a bimetallic effect is exploited to induce a linear expansion in the lapping plate so that the flatness or curvature of the lapping plate is manipulated with thermal cycling.
- 3. (unchanged) The system of claim 1, wherein the workpiece is a magnetic slider.
- 4. (unchanged) The system of claim 1, wherein the lapping plate can be configured in a flat, concave, or convex shape.
- 5. (unchanged) The system of claim 1, wherein the lapping plate gives the workpiece a high crown-to-camber ratio.
- 6. (canceled)
- 7. (currently amended) The system of claim [[6]] 1, wherein a middle diameter portion of the lapping plate is charged first, and then an inner diameter portion of the lapping plate and/or an outer diameter portion of the lapping plate.

- 8. (unchanged) The system of claim 1, wherein a temperature of the workpiece and the abrasive slurry are controlled along with the temperature of the lapping plate.
- 9. (unchanged) The system of claim 1, wherein the lapping plate is formed from a plurality of layers of materials having different coefficients of linear expansion.
- 10. (unchanged) The system of claim 9, wherein the layers are formed from metal alloys.
- 11. (unchanged) The system of claim 10, wherein the layers comprise a tin-antimony alloy adjacent to the workpiece, and a steel alloy base.
- 12. (unchanged) The system of claim 1, wherein the lapping plate comprises a material with a linear expansion coefficient of 23-x-10⁻⁶/°C bonded to another material with a linear expansion coefficient of 10-x-10⁻⁶/°C.
- 13. (unchanged) The system of claim 1, wherein the lapping plate gives the workpiece a negative crown and positive camber values.
- 14. (canceled)
- 15. (canceled)
- 16. (canceled)
- 17. (canceled)

Add the following new claims:

18. (new) The system of claim 1, wherein the means for controlling temperature comprises a temperature regulating unit that circulates fluid that travels between a thermal bath and a chuck holding the lapping plate.

- (new) The system of claim 1, wherein an interior air temperature of a facing tool is also 19. regulated during facing of the lapping plate.
- (new) A system for precisely controlling an amount of flatness or curvature of a lapping 20. plate, the system comprising:
 - a rotatable platform;
- a lapping plate mounted to the rotatable platform for rotation therewith, the lapping plate being formed from a plurality of layers of metal alloy materials having different coefficients of linear expansion;

a holder having a magnetic slider located between the holder and the lapping plate; an abrasive slurry located between the lapping plate and the magnetic slider;

means for controlling a temperature of the lapping plate, the magnetic slider, and the abrasive slurry, the means comprising a temperature regulating unit that circulates fluid that travels between a thermal bath and a chuck holding the lapping plate, and thereby precisely manipulating an amount of flatness or curvature of the lapping plate, such that a bimetallic effect is exploited to induce a linear expansion in the lapping plate so that the flatness or curvature of the lapping plate is manipulated with thermal cycling; wherein

the temperature of the lapping plate is adjusted during a charge process to selectively charge different areas of the lapping plate in a dictated order, and give the magnetic slider a high crown-to-camber ratio; and wherein

a middle diameter portion of the lapping plate is charged first, and then an inner diameter portion of the lapping plate and an outer diameter portion of the lapping plate.

- (new) The system of claim 20, wherein the lapping plate can be configured in a flat, 21. concave, or convex shape.
- (new) The system of claim 20, wherein the layers comprise a tin-antimony alloy adjacent 22. to the magnetic slider, and a steel alloy base.

- 23. (new) The system of claim 20, wherein the lapping plate comprises a material with a linear expansion coefficient of 23-x-10⁻⁶/°C bonded to another material with a linear expansion coefficient of 10-x-10⁻⁶/°C.
- 24. (new) The system of claim 20, wherein an interior air temperature of a facing tool is also regulated during facing of the lapping plate.